

L Number	Hits	Search Text	DB	Time stamp
1	129513	silicon near (layer film)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/03/16 10:27
6	82047	remov\$3 near2 heat	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/03/16 10:38
9	277075	(silicon near (oxide dioxide)) (sio."sub.2")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/03/16 10:38
12	22017	SOI (silicon near on near insulator) (silicon-on-insulator)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/03/16 10:40
13	246	(silicon near (layer film)) and (remov\$3 near2 heat) and ((silicon near (oxide dioxide)) (sio."sub.2")) and (SOI (silicon near on near insulator) (silicon-on-insulator))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/03/16 10:40